

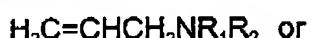
AMENDMENTS TO THE CLAIMS:

The listing of claims will replace all prior versions, and listings of claims in the application:

LISTING OF THE CLAIMS

1. (Currently Amended) [[An]] A process for the electrodeposition of a nickel or nickel-alloy coating on a substrate, the process comprising:

immersing the a metal substrate in a bath comprising nickel ions and an additive having the general formula:



wherein R₁, R₂ and R₃ are selected from the functional groups consisting [[or]] of hydrogen, methyl, ethyl, propyl, allyl, propyn, propanediol and combinations thereof; and X⁻ is an n-valent inorganic or organic anion; and

electrodepositing nickel onto the metal substrate.

2. (Currently Amended) The process according to claim 1 wherein X⁻ is an n-valent anion selected from the group consisting of chloride, bromide, fluoride, sulfate, acetate, and tetrafluoroborate.

3. (Currently Amended) The process according to claim 1 wherein the bath further comprises alloying metal alloys ions, and electrodepositing nickel onto the metal substrate comprises electrodepositing a nickel-alloy onto the metal substrate.

4. (Currently Amended) An aqueous acidic plating bath for the electrodeposition of a nickel or nickel alloy deposit on a substrate comprising:

a) nickel ions; and

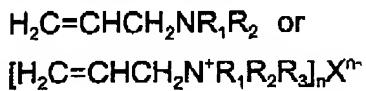
b) an additive having the general formula:



wherein R₁, R₂ and R₃ are selected from the functional groups consisting [[or]] of hydrogen, methyl, ethyl, propyl, allyl, propyn, propanediol and combinations thereof; and X⁻ is an n-valent inorganic or organic anion.

5. (Currently Amended) An aqueous acidic plating bath for the electrodeposition of a nickel or nickel alloy deposit on a substrate comprising:

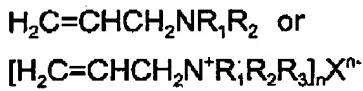
- a) nickel ions;
- b) at least one Class I brightener; and
- c) an additive having the general formula:



wherein R_1 , R_2 and R_3 are selected from the functional groups consisting [[or]] of hydrogen, methyl, ethyl, propyl, allyl, propyn, propanediol and combinations thereof; and X^- is an n-valent inorganic or organic anion.

6. (Currently Amended) An aqueous acidic plating bath for the electrodeposition of a nickel or nickel alloy deposit on a substrate comprising:

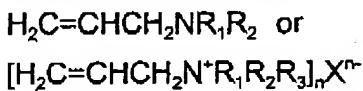
- a) nickel ions;
- b) at least one Class II brightener; and
- c) an additive having the general formula:



wherein R_1 , R_2 and R_3 are selected from the functional groups consisting [[or]] of hydrogen, methyl, ethyl, propyl, allyl, propyn, propanediol and combinations thereof; and X^- is an n-valent inorganic or organic anion.

7. (Currently Amended) An aqueous acidic plating bath for the electrodeposition of a nickel or nickel alloy deposit on a substrate comprising:

- a) nickel ions;
- b) at least one Class I brightener;
- c) at least one Class II brightener; and
- d) an additive having the general formula:

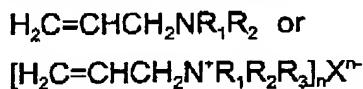


wherein R_1 , R_2 and R_3 are selected from the functional groups consisting [[or]] of hydrogen, methyl, ethyl, propyl, allyl, propyn, propanediol and combinations thereof; and X^- is an n-

valent inorganic or organic anion.

8. (Currently Amended) An aqueous acidic plating bath for the electrodeposition of a nickel or nickel alloy deposit on a substrate comprising:

- a) nickel ions;
- b) alloying metal ions;
- c) at least one Class I brightener;
- d) at least one Class II brightener; and
- e) an additive having the general formula:



wherein R_1 , R_2 and R_3 are selected from the functional groups consisting [[or]] of hydrogen, methyl, ethyl, propyl, allyl, ~~propyn~~-propanediol and combinations thereof; and X^n- is an n-valent inorganic or organic anion.

9. (Currently Amended) The bath according to claim 8 wherein the alloying metal ions are selected from the group consisting of iron, cobalt, tin, and zinc.

10. (Currently Amended) The bath according to claim 4 wherein X^n- is an n-valent anion selected from the group consisting of chloride, bromide, fluoride, sulfate, acetate, and tetrafluoroborate.

11. (New) The process according to claim 3, wherein the alloying metal ions are selected from the group consisting of iron, cobalt, tin, and zinc.

12. (New) The aqueous acidic plating bath according to claim 4, wherein the additive comprises diallylamine.

13. (New) The aqueous acidic plating bath according to claim 4, wherein the additive comprises triallylamine.

14. (New) The aqueous acidic plating bath according to claim 4, wherein the additive comprises diallyldimethyl ammonium chloride.

15. (New) The aqueous acidic plating bath according to claim 4, wherein the additive is present in an amount of from about 5 mg/l to about 160 mg/l.

16. (New) The aqueous acidic plating bath according to claim 4, wherein the additive is present in an amount of from about 5 mg/l to about 100 mg/l.

17. (New) The aqueous acidic plating bath according to claim 4, wherein the additive is present in an amount of from about 6 mg/l to about 80 mg/l.

18. (New) The process according to claim 1, wherein the additive comprises diallylamine.

19. (New) The process according to claim 1, wherein the additive comprises triallylamine.

20. (New) The process according to claim 1, wherein the additive comprises diallyldimethyl ammonium chloride.